



# Ion Implantation Techniques

By H. Glawischnig

Springer Dez 2011, 2011. Taschenbuch. Book Condition: Neu. 229x152x21 mm. This item is printed on demand - Print on Demand Neuware - In recent years, ion implantation has developed into the major doping technique for integrated circuits. Several series of conferences have dealt with the application of ion implantation to semiconductors and other materials (Thousand Oaks 1970, Garmisch-Partenkirchen 1971, Osaka 1974, Warwick 1975, Boulder 1976, Budapest 1978, and Albany 1980). Another series of conferences was devoted more to implantation equipment and techniques (Salford 1977, Trento 1978, and Kingston 1980). In connection with the Third International Conference on Ion Implantation: Equipment and Techniques, held at Queen's University, Kingston, Ontario, Canada, July 8-11, 1980, a two-day instructional program was organized parallel to an implantation conference for the first time. This implantation school concentrated on aspects of implantation-equipment design. This book contains all lectures presented at the International Ion Implantation School organized in connection with the Fourth International Conference on Ion Implantation: Equipment and Techniques, held at the Convention Center, Berchtesgaden, Germany, September 13-17, 1982. In contrast to the first school, the main emphasis in this school was placed on practical aspects of implanter operation and application. In...

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